

IN THE SPECIFICATION

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Kindly change the paragraph starting at page 10, line 25 as follows:

A schematic cross-section through one particular embodiment of a non-inverting translector 206 is presented in FIG. 2A. A translector layer 210 comprises a first microstructured layer 212 and a second microstructured layer 214. Between the two microstructured layers 212 and 214 is a microstructured partial dielectric reflector 216, that fits to the forms of the microstructured layer 212 and 214. The microstructured layers 212 and 214 are typically formed from optically transparent polymer materials.

Kindly change the paragraph starting at page 11, line 23 as follows:

A preferred approach to providing the microstructured partial dielectric reflector 216 is to provide a layered dielectric structure. A layered dielectric structure includes a number of dielectric layers having a different refractive index. One example of a layered microstructured dielectric reflector 216 is a single layer of a relatively high refractive index material disposed over a lower refractive index structured surface. In this case, an overlayer of a material having a relatively low refractive index may be on the other side of the relatively high refractive index layer from the lower refractive index structured surface. Examples of overlayers include a layer of air, or a planarization layer such as layer 214.

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Response to 1st Office Action